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**REMARKS** 

By the present amendment, independent claim 1 has been amended to further

clarify the concepts of the present invention. In particular, claim 1 has been amended to

restore the subject matter inadvertently canceled therefrom. Entry of the above

amendments is respectfully requested.

In the Office Action, claims 1-3, 5-8 and 10-12 again were rejected under 35 USC

§ 102(b) as being anticipated by, or alternatively, under 35 USC 103(a) as being obvious

over, the patent to Chatterjee. In making this rejection, it was alleged that the Chatterjee

patent teaches a resin composition for metallized films formed of components which fall

within the scope of the noted claims. In so doing, it was asserted that at least some of the

properties (a-1) through (a-6) of the propylene random copolymer (A) and the recited

properties for polyethylene resin (B), although not specifically disclosed, would be inherent

in the compositions according to the cited patent. Reconsideration of this rejection in view

of the above claim amendments and the following comments is respectfully requested.

Before discussing the rejection in detail, again a brief review of the presently

claimed invention may be quite instructive. The subject invention relates to a

polypropylene-based resin composition for metallized films where the composition

comprises, among other things, a propylene random copolymer (A) produced in the

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presence of a metallocene catalyst, which has the properties (a-1) to (a-6) as now recited

in claim 1. An extremely important feature of this composition is that the propylene random

copolymer (A) (hereinafter simply referred to as "copolymer (A)") is produced in the

presence of a metallocene catalyst. In other words, it is extremely difficult, if not

impossible, to produce the copolymer (A) without using a metallocene catalyst, that is, for

example, in the presence of a conventional Ziegler-Natta type catalyst. It submitted that

such a polypropylene-based resin composition for metallized films which includes

copolymer (A) as defined in claim 1 is not taught or suggested by the cited patent to

Chatterjee.

Among other things, it is submitted that the Chatterjee patent does not teach or

suggest, among other things, the use of a metallocene catalyst for the production of a

polypropylene random copolymer. In support thereof, attention is directed to column 2,

lines 4 to 9 of the <u>Chatterjee</u> patent which teaches:

"For example, the base polymer may be prepared by polymerizing propylene

and an  $\alpha$ -olefin having 5 to 8 carbon atoms under polymerization conditions

in the presence of a titanium-based, olefin polymerization catalyst system

such as a magnesium halide-supported titanium-containing polymerization

catalyst system."

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Attention further is directed to column 3, lines 23 to 26 of the Chatterjee patent which

teaches:

"Acid acceptors act to neutralize acidic species, such as hydrochloric acid

(HCI), which are residues from the polymerization catalyst system such as

the Ziegler-Natta type catalyst system."

These two specific teachings from the Chatterjee patent strongly suggest that a Ziegler-

Natta type catalyst is used for producing the propylene random copolymer. Therefore,

according to the teachings of the Chatterjee patent, the amount and molecular weight of

the solubles of the resultant propylene random copolymer are not well-balanced. As a

consequence, the properties of the resultant metallized film are unsatisfactory.

In the rejection, it was acknowledged that the <u>Chatterjee</u> patent does not specifically

disclose that the polypropylene random copolymer of the composition according to the

patent has all the properties as recited in the subject claims. However, it was asserted that

the components of the resin composition of the cited Chatterjee patent would be expected

to possess the same properties as recited in the claims. In other words, it was asserted

that the components of the composition of the cited Chatterjee patent would inherently

have the same properties as the composition as claimed.

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It is submitted that, contrary to the above assertion, the propylene random

copolymer of the composition according to the Chatterjee patent does not in fact have one

or more of the properties as claimed. In this regard, specific attention is directed to the

enclosed Declaration of Mr. Yasunori Nakamura, one of the inventors in the subject

application. From the evidence of the experiments as recounted in the Declaration, it is

to be specifically noted that Mr. Nakamura has concluded that the propylene random

copolymer used in the Chatterjee patent is completely different from copolymer (A) in the

presently claimed invention, and cannot be used for preparing the composition of the

present invention for metallized films. Thus, the Declaration clearly demonstrates that the

teachings of cited Chatterjee patent do not produce a copolymer (A) having properties (a1)

through (a-6) as recited in present claim 1.

In summary and as apparent from the above, it is submitted that the Chatterjee

patent does not teach or suggest the essential features and unexpected effects of the

presently claimed invention. That is, the production method and properties of copolymer

(A) of the polypropylene-based resin composition for metallized films of the presently

claimed invention must be as specified as in claim 1, in order to obtain a metallized film

with satisfactory properties. The subject Declaration clearly demonstrates that the

properties of copolymer (A) as claimed are only achieved according to the subject invention

and such are not obtainable in accordance with the teachings of the **Chatterjee** patent.

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For the reasons stated above, withdrawal of the rejection under 35 U.S.C. § 102(b)

or 35 U.S.C. § 103(a) and allowance of claims 1, 3, 5-7, 9 and 11-12 as amended over the

cited **Chatterjee** patent are respectfully requested.

In view of the foregoing, it is submitted that the subject application is now in

condition for allowance and early notice to that effect is earnestly solicited.

In the event this paper is not timely filed, the undersigned hereby petitions for an

appropriate extension of time. The fee for this extension may be charged to Deposit

Account No. 01-2340, along with any other additional fees which may be required with

respect to this paper.

Respectfully submitted,

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